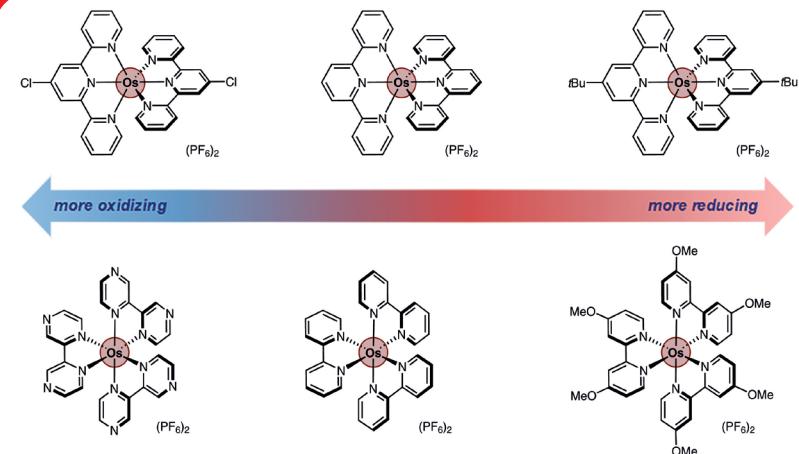


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Tuning the Electrochemical and Photophysical Properties of Osmium-Based Photoredox Catalysts

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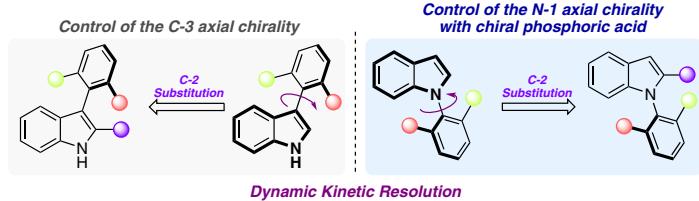
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Thieme

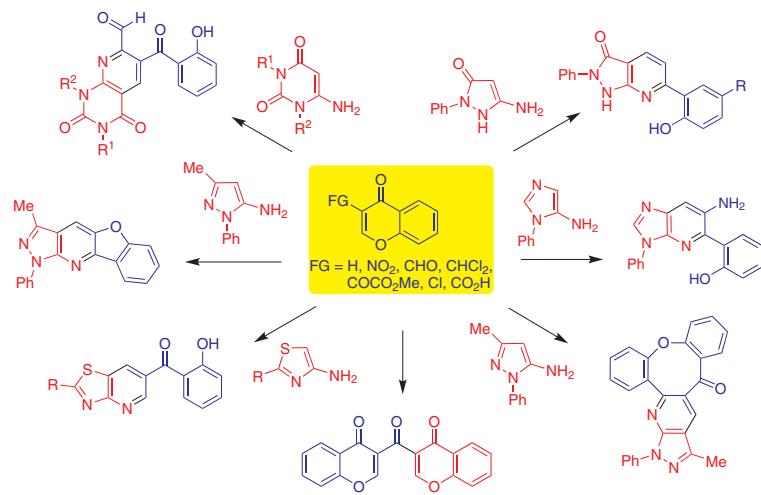
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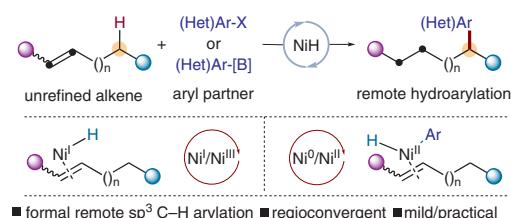
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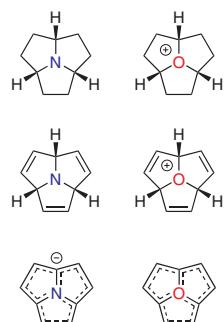
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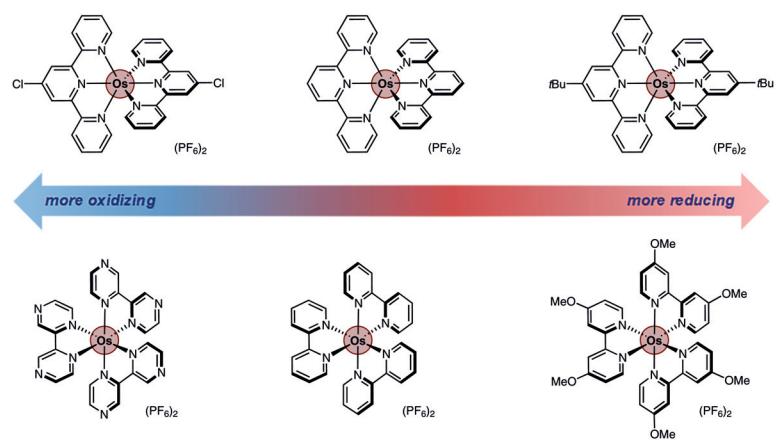
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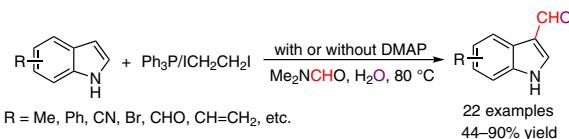


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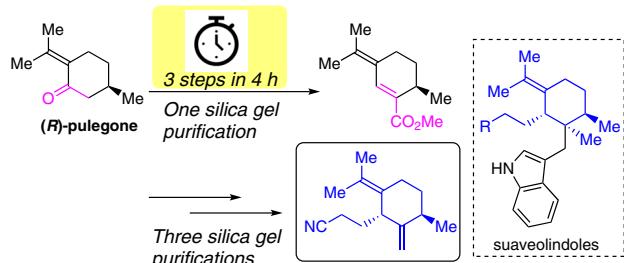


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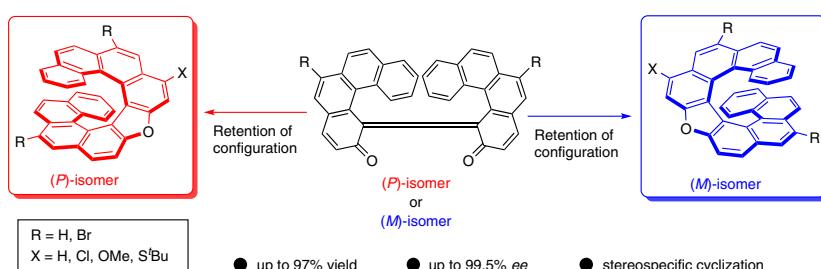
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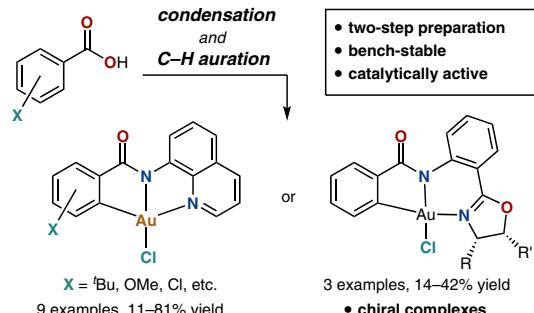
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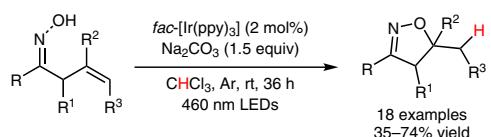
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